



This website uses cookies to improve the user's experience during working with our network and to provide users with dedicated services and functions. By further use you agree with that.OKDetails

Adresse	Busch Vacuum Pumps and Systems
	Schauinslandstr. 1
	79689 Maulburg
Pays	Allemagne

PRODUITS OU MACHINES

Vacuum plays a decisive part in many coating operations in which metals, plastics or glass are deposited in vapour form. In many cases these processes would not be possible without vacuum. A medium or high vacuum is applied to the chamber for its evacuation at the start of the process, after which reaction gases are extracted or solid raw materials vapourized.

All these processes have a common requirement: a completely reliable medium or high vacuum in the chamber that precisely matches the coating process. Such coating operations are carried out to alter the surface characteristics of the material, such as hardness or resistance to corrosion. Vacuum coating may also be used to improve the adhesive or wetting qualities of the material, or to make surfaces permanently hydrophobic or hydrophilic.

Our vacuum systems are delivered with made-to-measure components for all types of vacuum-based coating processes.

Which Busch vacuum solutions are especially suitable for coating processes?

Our product range includes a large number of different vacuum solutions for coating processes, and we supply individual pumps or complete vacuum systems.

COBRA screw vacuum pumps are ideally suited to these applications, and in combination with vacuum-boosters are a proven standard solution for medium vacuum applications.

The large number of variants of both COBRA and vacuum-boosters enables vacuum systems to be designed to match the process exactly. For high vacuum applications we offer Turbo turbomolecular vacuum pump and Rangu diffusion vacuum pump series, which in combination with a backing pump may be configured to suit the coating process precisely.

Examples of Busch Vacuum technology in coating processes:

Physical Vapour Deposition (PVD) Chemical Vapour Deposition (CVD) Metallization

Company Profile of Busch Vacuum Pumps and Systems

A service of glassglobal.com, an affiliate of glassglobal group.

Les informations publiées sur ce document sont soumises au droit d'auteur et appartiennent à la société en question resp. à la source des addresses. Tous les droits sont réservés expressément. N'importe quel utilisateur qui accède à un tel matériel peut faire ainsi seulement pour sa propre utilisation personnelle, et l'usage d'un tel matériel est au risque unique de l'utilisateur. La redistribution ou toute autre exploitation commerciale des addresses est expressément interdite. Là où une addresse est fournie par un tiers, chaque utilisateur accepte d'observer et être lié par les limites spécifiques de l'utilisation. Glass Global ne représente ou n'approuve pas l'exactitude ou la fiabilité d'aucune des informations citées dans les adresses ou pages externes auxquelles l'on se réfère ici.www.glassglobal.com - The International Portal to the Glass Industry - OGIS GmbH